

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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CENTRAL FAX CENTER**Serial No.:** 10/707,388**Conf. No.:** 1387**OCT 14 2005****Filing Date:** 12/10/2003**Art Unit:** 2891**Applicant:** Divakaruni et al.**Examiner:** Fulk, Steven J.**Title:** SILICIDE RESISTOR IN BEOL  
LAYER OF SEMICONDUCTOR  
DEVICE AND METHOD**Docket No.:** FIS920030274US1  
(IBM-0032)**COMMISSIONER FOR PATENTS****DESTINATION FACSIMILE NUMBER:** 571-273-8300Transmitted herewith is: **Request for Reconsideration in 8 pages**

in the above identified application.

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**In Re Application of:** Divakaruni et al.

**Conf. No.:** 1387

**Serial No.:** 10/707,388

**Art Unit:** 2891

**Filed:** 12/10/2003

**Dkt. #:** FIS920030274US1 (IBMF-0032)

**Title:** SILICIDE RESISTOR IN BEOL  
LAYER OF SEMICONDUCTOR  
DEVICE AND METHOD

**Examiner:** Fulk, Steven J.

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**REQUEST FOR RECONSIDERATION**

Sir:

**I. INTRODUCTORY COMMENTS:**

In response to the Office Action of July 28, 2005, please reconsider the above-referenced patent application in view of the following remarks:

Appl. No. 10/707,388  
Reply to Office Action of 07/28/05

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